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## Preparation of hybrid coating film between magneto-optical and hologram layers

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INTRODUCTION Bismuth substituted yttrium iron garnet (Bi-YIG) is the most excellent magneto-optical material because it exhibits huge Faraday rotation [1,2]. We have been studying the preparation process and applications of Bi-YIG nanoparticles and their coating films [3,4]. In this study we will propose a hybrid material of magneto-optical coating layer and hologram sheet film.

EXPERIMENTS AND RESULTS Bi<sub>1.8</sub>Y<sub>1.2</sub>Fe<sub>5</sub>O<sub>12</sub> particle was prepared by coprecipitation and annealing processes [3]. The nanoparticles were mixed with a cyclohexanone and a dispersant. Then the mixtures were milled by planetary milling machine with 48 h. The magnetic fluids of Bi-YIG nanoparticles were coated by a rod coater on a plastic film which has preformative hologram images. The magneto-optical hologram (MO-hologram) film were obtained (Fig.1). Fig.2 shows the magneto-optical contrast observed with the MO-hologram film. The MO-hologram film is a flexible and low cost magneto-optical material. We will be present film form magneto-optical materials on the conference.

## References

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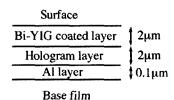
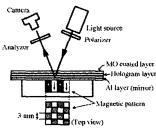


Fig.1. Stack of magneto-optical hologram sheet.



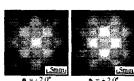


Fig. 2 Schematic diagram of the ptical configuration used for the observation of magneto-optical contrasts;  $\phi$ : offset angle of analyzer.

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